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SIMPLIFIED DESIGN OF MULTILAYERED SUBSTRATE-INTEGRATED WAVEGUIDE RIBLET-SAAD COUPLERS

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ABSTRACT: A simplified design procedure for dual- and triple-layered Riblet–Saad directional couplers in substrate-integrated waveguide (SIW) technology is presented. Emphasis is placed on a design that considers ease of fabrication and includes interface ports such as microstrip-to-SIW transitions with straight, bent, and mitered microstrip lines. Designs are performed in an HFSS environment, which is verified by comparison with an independent field-solver simulation. © 2010 Wiley Periodicals, Inc. Microwave Opt Technol Lett 52: 1142–1144, 2010; Published online in Wiley InterScience (www.interscience. wiley.com). DOI 10.1002/mop.25149

Key words: substrate-integrated waveguide; multilayered E-plane couplers; Riblet–Saad directional couplers

1. INTRODUCTION

Substrate-integrated waveguide (SIW) technology has found many applications in the millimeter-wave frequency range, for example [1, 2], because it presents a reasonable compromise between microstrip and rectangular-waveguide circuitry. One of the advantages for the design of SIW components is that after dispersion characteristics and via hole dimensions have been related to all-dielectric-filled rectangular waveguides [3], traditional waveguide design strategies, for example, [4], can be used. Moreover, tapers to microstrip technology [5] provide an interface to measurement equipment.

Because of its planar nature, SIW applications are preferably fabricated in H-plane circuitry. Filters, diplexers, power dividers, and H-plane couplers are some of the preferred components, for example, [1, 6–8]. To integrate this technology with two-dimensional antenna arrays [9], however, coupling between stacked SIW components must be facilitated. Attempts to incorporate multilayered SIW circuits for antenna feed networks have been made in [8, 10] in the form of an E-plane directional couplers.

This article presents simplified design guidelines for dualand triple-layered Riblet–Saad SIW E-plane couplers. The designs include tight coupling and interface ports with straight, bent, and mitered microstrip transitions.

2. DESIGN

Figure 1 shows an eight-section dual-layer [Fig. 1(a)] and two triple-layer [Figs. 1(b) and 1(c)] Riblet–Saad couplers in SIW technology with straight, bent, and mitered microstrip ports. Note that a coupling aperture is represented by a slot pair—one in longitudinal and the other in transverse direction.

For the design of the SIW components, the substrate material as well as the placement, dimensions, and shapes of via holes must be selected. These parameters are usually dictated by the fabrication process involved. We assume standard printed-circuit board facilities and select RT Duroid with $\varepsilon_r = 2.2$, height b = 0.508 mm, and metallization thickness $t = 35 \ \mu m$ as substrate



Figure 1 Eight-section Riblet–Saad couplers in SIW technology: (a) dual-layer with bent microstrip ports, (b) triple-layer with straight and bent microstrip ports, (c) triple-layer with straight and mitered microstrip ports

material. We assume circular vias of diameter 2r = 1.19 mm and calculate their center-to-center spacings in width and length as a = 5.53 mm and p = 2.38 mm, respectively, from closeform expressions in [3, 5]. This leads to an equivalent all-dielectric-filled waveguide width of $a_{equ} = 4.79$ mm [5]. A transition from this SIW to microstrip can be obtained from [5]. The width of the 50- Ω microstrip line is 1.67 mm, the width at the SIW junction is 1.80 mm, and the length of the linear taper between these two widths is 4.27 mm. These dimensions are displayed in Figure 2. Bends and mitered corners are designed using standard procedures as outlined, for example, in [11].

The design process for the aperture dimensions follows, in principle, the equivalent-circuit synthesis approach of [4] and includes the aperture thickness ($2t = 70 \ \mu m$) of the top and bottom metallization of the stacked SIWs. However, to avoid overlapping apertures for tight coupling and maintain ease of fabrication, all apertures in this simplified design are preset to be identical. For given specification and number of apertures, the equivalent-circuit parameters as obtained from [4] are averaged so that every aperture contributes the same amount of coupling. This leaves only a single aperture to be designed for which the design parameters are (c.f. Fig. 2): the lengths of the longitudinal (l_1) and transverse (l_t) slots, and the distance s from the center of the longitudinal slot to the centerline of the guide. The widths of the longitudinal (w_1) and transverse (w_t) slots are set to standard end-mill cutter diameters of 0.154 mm and 0.1 mm, respectively. Finally, all center-to-center distances d between apertures are set to one quarter of the electrical length at the midband frequency. Parameter d is the only dimension that is varied during a final one-dimensional optimization in HFSS to improve return loss and isolation.

Note that after an initial design is obtained following the earlier procedure, the coupling value usually deviates from its target by a few dB. This is because of the fact that the fields are averaged over all slots to coincide with a single combined equivalent-circuit parameter. The initial design is thus repeated for a coupling value to offset the deviation obtained in the previous step. Triple-layer couplers are designed in the same way as dual-layer components but for an initially lower coupling value, considering the fact that coupling will double once the third layer is added.

3. RESULTS

The first design example is a 3-dB eight-section dual-layer Riblet–Saad coupler according to Figure 1(a). Figure 3 shows a



Figure 2 Top view and dimensions (in mm) of SIW-to-microstrip transition and coupling slots as explained in Section 2



Figure 3 Dual-layer eight-section 3-dB Riblet–Saad coupler with microstrip-to-SIW transitions according to Figure 1(a): performance comparison between HFSS and CST for return loss and isolation (a) and performance comparison between HFSS and CST for through port and coupled port (b)

comparison between results obtained with HFSS and CST Microwave Studio. Port assignments are: input port (1), through port (2), coupled port (3), and isolated port (4). The comparisons between HFSS and CST for return loss and isolation [Fig. 3(a)] and for coupled and through ports [Fig. 3(b)] show good agreement, especially when considering that both field solvers include all four SIW-to-microstrip transitions. Figure 3, thus, validates the simplified design procedure as outlined in the previous section. A comparison with measurements obtained from a 3-dB SIW coupler with 14 dual-hole apertures (instead of the Riblet–Saad configurations presented here) has already been presented in [10] and will not be repeated.

As a second example, Figure 4 shows the performances of two triple-layer eight-section Riblet–Saad couplers. The design in Figure 4(a) features bent [Fig. 1(b)] microstrip connections, whereas that in Figure 4(b) uses mitered ones [Fig. 1(c)]. For this arrangement, the center layer operates as the input (1) and through port (2); coupled ports are (3) and (5), isolated ports (4) and (6). The couplers are designed for three-way power division, that is, 4.78 dB, between the through port and the two coupled ports. It is clearly observed that the coupler with bent microstrip ports [Fig. 4(a)] achieves better return loss and isolation performance compared with the one with mitered sections [Fig.



Figure 4 Performances of triple-layer eight-section Riblet–Saad 4.78dB couplers with (a) straight/bent microstrip ports according to Figure 1(b) and (b) straight/mitered microstrip ports according to Figure 1(c)

4(b)]. As a result, the power splitting performance in Figure 4(a) is fairly constant over almost the entire Ka-band.

For completeness, Table 1 presents the aperture dimensions of the two couplers presented in Figures 3 and 4. The remaining design parameters and nomenclature are as outlined in Figure 2 and Section 2.

4. CONCLUSIONS

The simplified design approach presents a viable option for multilayered coupler design in SIW technology. It contributes to simple fabrication due to keeping identical all apertures dimensions in a coupler and maintaining a constant distance between them. Dual- and triple-layered Riblet– Saad couplers with power divisions of 3 dB and 4.78 dB are presented as examples of multilayered SIW technology. The basic design procedure is performed in an HFSS environment and validated by comparison with results obtained with another commercially available software package. For access to all ports, microstrip-to-SIW transitions are included and are shown to influence the performance of the Riblet–Saad SIW couplers.

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TABLE 1 Aperture Dimensions in mm

Coupling (dB)	Longitudinal Slots	Transverse Slots	Distance Between Apertures	
				Figure
3	$l_1 = 2.55$	$l_{\rm t} = 1.25$	d = 1.98	3
	$w_1 = 0.154$	$w_{\rm t} = 0.10$		
	s = 1.37			
4.78	$l_1 = 2.25$	$l_{\rm t} = 1.40$	$= 1.40 \qquad d = 1.98$	4
	$w_1 = 0.154$	$w_{\rm t} = 0.10$		
	s = 1.37			